

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4	(etch\$3 pattern\$3 deash\$3) near20 (resist photoresist (photo near3 resist)) near20 (hydrocarbon and oxygen and argon)	US-PGPU B; USPAT; USOCR	OR	ON	2005/02/16 18:42
L2	11	(etch\$3 pattern\$3 deash\$3) and (resist photoresist (photo near3 resist))and (hydrocarbon and oxygen and argon)	EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/16 18:43